

<b>Notice of References Cited</b>	Application/Control No. 10/799,922		Applicant(s)/Patent Under Reexamination HOFLAND ET AL.	
	Examiner Gollamudi S. Kishore, Ph.D		Art Unit 1615	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-2001/0033862	10-2001	Hostetler et al.	424/450
*	C	US-6,121,245	09-2000	Firshein, Richard N.	514/34
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	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Spevak et al in J. Amer. Chem. Soc. (1993), vol. 115, pp. 1146-1147.
	V	Zips et al in IN VIVO, (2005) vol. 19, pp. 1-7
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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